

L Number	Hits	Search Text	DB	Time stamp
1	1430	((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:09
2	100	((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:09
3	96	((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:10
4	8	((422/198,194,190,110).CCLS.) or ((422/129,139,145,146,147) or (118/716)).CCLS.) and (silicon near granule)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:11
5	461	((422/198,194,190,110).CCLS.) or ((422/129,139,145,146,147) or (118/716)).CCLS.) and (silicon)) not (((422/198,194,190,110).CCLS.) or ((422/129,139,145,146,147) or (118/716)).CCLS.) and (silicon near granule))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:11
6	337	((422/198,194,190,110).CCLS.) or ((422/129,139,145,146,147) or (118/716)).CCLS.) and (silicon) and heat\$3) not (((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) not (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3) (((422/198,194,190,110).CCLS.) or ((422/129,139,145,146,147) or (118/716)).CCLS.) and (silicon near granule)) (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:12
7	335	(heat\$3 adj (section or zone or chamber)) and (react\$3 adj (section or zone or chamber)) and puls\$3 and (gas same (nozzle or inject\$3 or inlet)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:15
8	4	((heat\$3 adj (section or zone or chamber)) and (react\$3 adj (section or zone or chamber)) and puls\$3 and ((nozzle or inject\$3 or inlet)))) and (silicon near granule)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:18

10	53	((((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) (((((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3) (((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) (((((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon near granule)) (((((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon)) not (((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon near granule))) (((((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon) and heat\$3) not ((((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) not (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3) (((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.)) and (silicon near granule)) (((((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3 adj (section or zone or chamber)) and (react\$3 adj (section or zone or chamber)) and puls\$3 and (gas same (nozzle or inject\$3 or inlet))) (((heat\$3 adj (section or zone or chamber)) and (react\$3 adj (section or zone or chamber)) and puls\$3 and ((nozzle or inject\$3 or inlet))) and (silicon near granule))) and @pd>=20040107 ((422/129,139,145,146,147) or (118/716)).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:20
	2838		USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/07 09:46
	1409	((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:09
	94	((((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:09
	2	("20020081250").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/06 18:18
	3254	(422/198,194,190,110).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/07 09:00
	92	((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:10
	87	((((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) not (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/07 09:01

	2838	((422/129,139,145,146,147) or (118/716)).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/07 09:46
	8	((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.) and (silicon near granule)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:11
	439	(((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.) and (silicon)) not (((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.) and (silicon near granule))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:11
	94	(((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/07 10:59
	324	(((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.) and (silicon) and heat\$3) not (((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) not (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3) (((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.) and (silicon near granule)) (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:12
	319	(heat\$3 adj (section or zone or chamber)) and (react\$3 adj (section or zone or chamber)) and puls\$3 and (gas same (nozzle or inject\$3 or inlet))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/15 19:13
	311	((heat\$3 adj (section or zone or chamber)) and (react\$3 adj (section or zone or chamber)) and puls\$3 and (gas same (nozzle or inject\$3 or inlet))) not (((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) (((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) not (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3) (((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.) and (silicon near granule)) (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3) ((((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.) and (silicon) and heat\$3) not (((422/198,194,190,110).CCLS.) and heat\$3 and puls\$3) not (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3) (((422/198,194,190,110).CCLS.) or (((422/129,139,145,146,147) or (118/716)).CCLS.) and (silicon near granule)) (((422/129,139,145,146,147) or (118/716)).CCLS.) and heat\$3) and puls\$3))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/08 10:15
	4	((heat\$3 adj (section or zone or chamber)) and (react\$3 adj (section or zone or chamber)) and puls\$3 and (gas same (nozzle or inject\$3 or inlet))) and (silicon near granule)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/01/08 10:24

